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Lock-in Amplifier Based Peak Force Infrared Microscopy

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Nanoscale infrared (nano-IR) microscopy enables label-free chemical imaging with a spatial resolution below Abbe's diffraction limit through the integration of atomic force microscopy and infrared radiation. Peak force infrared (PFIR) microscopy is one of the emerging nano-IR methods that provides non-destructive multimodal chemical and mechanical characterization capabilities using a straightforward photothermal signal generation mechanism. PFIR microscopy has been demonstrated to work for a wide range of heterogeneous samples, and it even allows operation in the fluid phase. However, the current PFIR microscope requires customized hardware configuration and software programming for real-time signal acquisition and processing, which creates a high barrier to PFIR implementation. In this communication, we describe a type of lock-in amplifier-based PFIR microscopy that can be assembled with generic, commercially available equipment without special hardware or software programming. We demonstrate this method on soft matters of structured polymer blends and blocks, as well as biological cells of *E. coli*. The lock-in amplifier-based PFIR reduces the entry barrier for PFIR microscopy and makes it a competitive nano-IR method for new users.

Introduction

Infrared (IR) spectroscopy and microscopy are convenient and non-invasive analytical techniques for identifying chemical compositions. However, Abbe's diffraction limit prevents traditional infrared microscopy from reaching nanoscale spatial resolution¹; therefore, nanoscale heterogeneous samples, such as structured polymers and biological cells, cannot be easily resolved spatially with infrared microscopy. Atomic force microscopy (AFM) was combined with infrared radiation to bypass the optical diffraction limit, leading to the development of two popular families of AFM-based IR methods. The first family, scattering-type scanning near-field optical microscopy (s-SNOM), is based on the optical detection of scattered light from the near field of a sharp metallic AFM tip near the sample.^{2, 3} s-SNOM delivers 10~20 nm spatial resolution. It is a widely used technique to study heterogeneous samples with strong spatial contrast of dielectric functions and twodimensional materials that support polaritons.⁴

The other family of methods, and an increasingly popular AFMbased infrared spectroscopy method for soft matters, is the AFM-IR, which mechanically detects the photothermal response of the sample due to IR absorption. Since its early conception and demonstration,^{5, 6} AFM-IR has been developed

58 59 60 with different AFM operational modes:⁷ the original photothermal induced resonance (PTIR) technique that is based on contact mode,^{8, 9} photo-induced force microscopy (PiFM),^{10, 11} or tapping AFM-IR, that is based on tapping mode,^{9, 12} and peak force infrared (PFIR) microscopy that is based on the peak tapping mode.^{13, 14} These AFM-IR techniques inherit the same advantages and limitations of their respective AFM operational modes.

PFIR microscopy, a peak force tapping-based AFM-IR method, delivers а multimodal chemical and mechanical characterization platform. PFIR microscopy has been applied to a range of nanoscale heterogeneous samples, from polymers and biological specimens to oil shale source rock and polaritonic materials.¹⁵⁻¹⁹ PFIR microscopy also enables nanoscale IR microscopy and spectroscopy in the liquid/aqueous phase,^{20, 21} leveraging the suitability of peak force tapping mode in the fluid phase. Recent development of PFIR microscopy has been the integration of the surface potential mapping ability of pulsed force Kelvin probe force microscopy, which delivers simultaneous chemical, mechanical, and surface potential mapping in one AFM mode.¹⁸ However, despite the successful demonstration of PFIR microscopy, its popularity is limited by the complexity of its customized signal generation and processing routine. A typical PFIR microscope requires hardware or software-level programming on signal acquisitions and processing, which often involves programming with LabVIEW or equivalent platforms. The necessity of mastering these programming tools for utilization creates an entry barrier for spectroscopists or analytical chemists. In contrast, both PTIR and PiFM/tapping AFM-IR can be assembled with standard commercially available hardware without programming. The

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data can be acquired with lock-in amplifiers in PTIR and PiFM/tapping AFM-IR.

How can the signal processing of PFIR microscopy be simplified to reduce the technical barrier to its wider adaptation? In this article, we describe our development of a lock-in amplifierbased variant of PFIR microscopy that can be assembled with commercially available instruments and without the necessity for customized hardware or software for signal acquisition and data processing.

Method

16 PFIR microscopy operates in peak force tapping (PFT) mode,²² 17 also known as pulsed force mode.²³ In PFT mode, the AFM tip 18 intermittently indents into the sample surface under an 19 external peak force set point regulated by a negative feedback 20 loop. The PFT frequency is typically set at a low value, e.g., 4 21 kHz, which is much lower than that of the cantilever resonant 22 frequency that the regular tapping mode operates at. PFIR 23 inherits the advantages of PFT mode and is suitable to various 24 samples of different moduli and surface roughness. Compared 25 with traditional contact mode and tapping mode, PFT mode 26 offers deterministic tip-sample contact, and at the same time, it 27 avoids scratching the sample with the tip. As an AFM-IR method, 28 PFIR utilizes the temporal regime when the tip and sample are 29 in dynamic contact to measure the photothermal effect. The IR 30 laser emissions are synchronized with the PFT cycle and 31 adjusted to the moment when the tip and sample are in contact. 32 The photothermal expansion of the sample causes the 33 cantilever to deflect and oscillate, which in regular PFIR 34 microscopy, is usually recorded by a data acquisition card with 35 gated detection. The cantilever response due to the sample's 36 photothermal expansion is then processed with customized 37 software written in LabVIEW to obtain the PFIR signal in real-38 time. This real-time data treatment usually involves a Fast-39 Fourier Transform of the time-domain deflection trace with 40 subsequent integration around the IR-induced cantilever 41 oscillation frequencies.¹³ The PFIR signal is recorded while the 42 AFM tip scans over the sample to form a PFIR image. With 43 regular PFIR operation, the challenge for widespread adaption 44 is the customized signal acquisition and processing software, 45 which is specific to certain hardware (e.g., a data acquisition 46 card) and requires expertise in programming to achieve 47 mastery.

49 To overcome this problem, our lock-in based PFIR microscopy 50 instead uses a commercially available lock-in amplifier for data 51 acquisition and processing, rather than requiring software or 52 hardware-level programming. The apparatus consists of a peak 53 force tapping enabled AFM (Multimode 8, Bruker Nano), an 54 externally triggerable mid-infrared quantum cascade laser in 55 pulsed mode (QCL, MIRcat-QT, DRS Solutions), a multi-function 56 lock-in amplifier (MPLi-5M-MF, Zurich Instruments), a function 57 generator (HDG6112B, Hantek) and an assembly of standard 58 optics. Figure 1a schematically illustrates the construction of 59 the lock-in based PFIR microscope. The IR radiation beam from

the QCL is expanded and guided to a parabolic mirror (Edmund Optics, effective focal length of 25.4 mm) mounted on a threedimensional translation stage to position its focus on the AFM tip apex. The polarization of the IR light is parallel to the long axis of the AFM tip. The AFM operates at 4 kHz in peak force tapping frequency with a low peak force amplitude of 30 nm. A platinum-coated AFM tip (MikroMasch NSC:15/Pt) is used to enhance the IR radiation under its apex. The tip-enhanced infrared field excites the vibrational resonance of the sample and induces photothermal expansion. Since the pulsed duration of the QCL is at tens to hundreds of nanoseconds, the rapid photothermal expansion of the sample is capable of impulsively exciting the AFM cantilever, causing deflection and oscillation.



Figure 1. (a) The schematic illustration of the components of a lock-inbased PFIR microscope. (b) Schematic of excitation timing of the QC (c) Excitation scheme of the lock-in based PFIR microscopy. The grey curve represents the cantilever's vertical deflection signal when the IR laser illumination is off. The blue curve represents the cantilever's vertical deflection signal when the IR laser is in resonance (1492 cm⁻¹) with the polystyrene sample. Red lines represent the timing of laser pulses. 1 2

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The magnitude of AFM cantilever deflection is detected by a quadrant diode from a laser beam reflected off the back of the cantilever.

7 In our development, the voltage waveform of the vertical 8 deflection from the quadrant diode is routed to one channel of 9 the lock-in amplifier to generate a phase-locked transistor-to-10 transistor logic (TTL) waveform at the peak force tapping 11 frequency f. The multichannel lock-in amplifier is acting as a 12 phase-locked loop (PLL). The TTL waveform triggers the function 13 generator to produce a TTL pulse train, with the ON state 14 synchronized with the peak force tapping cycle when the tip-15 sample is in contact. We call this TTL pulse train the TTL timing 16 mask. We use the second channel of the lock-in amplifier to 17 generation a high frequency TTL train at a reference frequency 18 19 of F, which is the integer multiple of the peak force tapping frequency f. The value of F can be set at a range of high 20 frequencies, so long as it avoids the cantilever free space 21 oscillation frequency. In our case, the reference frequency is set 22 23 to be around 2 times the cantilever free space oscillation frequency. The TTL pulse train at F and the TTL time mask are 24 then processed by a TTL trigger mask circuit that functions as a 25 logic AND gate. The result of the operation is to only leave the 26 TTL pulse ON when the tip sample are in momentary contact. 27 The resulting TTL pulse train is routed to the QCL to trigger laser 28 emissions. Timing of this operation is illustrated in Figure 1b. In 29 this triggering configuration, there is no IR emission from the 30 QCL when the tip and sample are not in contact during the PFT 31 cycle. The purpose is to avoid unnecessary background 32 photothermal signals from heating the AFM cantilever alone, 33 without the participation of the sample. The photothermal 34 expansion of the sample due to IR absorption by the pulse train 35 causes additional cantilever oscillations, as shown by Figure 1c. 36 The vertical deflection signal waveform of the quadrant 37 38 photodiode of the AFM is routed to the multichannel lock-in amplifier. The reference frequency for the lock-in detection is 39 set at F, which is the repetition rate of the IR pulse train within 40 each pack of emission. 41

Like other variations of PFIR microscopy, lock-in based PFIR 43 microscopy has two operational modes: IR imaging and point 44 spectroscopy. In the IR imaging mode, the QCL is set to a 45 radiation frequency of interest, usually matching one of the 46 functional groups of the sample. Then, the lock-in 47 demodulation signal is recorded and routed to the AFM 48 controller to be registered together with the AFM topography 49 to create an image. In point spectroscopy, the AFM tip remains 50 at one location of interest on the sample, and the radiation 51 frequency of the QCL is swept while the lock-in demodulation 52 signal is recorded. Correlating the lock-in signal with the IR 53 frequency forms a nano-IR spectrum. Such spectrum collection 54 can be done with a simple LabVIEW software to sweep the IR 55 frequency and record the lock-in signal. Alternatively, one can 56 use built-in data acquisition functionality of advanced modern 57 lock-in amplifiers (e.g. MFLi, Zurich Instruments), triggered by a 58

frequency sweeping event from the QCL, which is usually a TTL pulse.

Results

To demonstrate the feasibility of lock-in based PFIR microscopy, the first sample we measured was the polymer blend of polystyrene (PS) and polymethylmethacrylate (PMMA). The blend polymer sample was prepared by spin-coating the 30 mg/mL (PS:PMMA = 1:1.5) solution in toluene on a gold



Figure 2. Lock-in PFIR imaging and spectroscopy of a PS:PMMA blend polymer film. (a,b) AFM topography and adhesion of the PS:PMMA blend polymer. (c,d) Lock-in PFIR images of the PS:PMMA blend polymer at 1492 cm⁻¹ and 1724 cm⁻¹ at the infrared absorption peaks of PS and PMMA, respectively. (e) PFIR spectra after spline smoothing of the PS:PMMA blend polymer film. The blue and green marked spots on the topography image in panel (a) are the positions at which the spectra of PMMA (blue curve) and PS (red curve) domains were collected, correspondingly.

substrate. The spin-coater (KW-4A, Nanomicrotools) was set to 460 revolutions per minute (rpm) for 6 seconds and 1100 rpm for 60 seconds.

Figure 2 presents the measurement results with the topography of an area on the polymer blend in panel (a). Figure 2b displays the simultaneously collected adhesion through the PeakForce Tapping QNM. Figure 2c shows the lock-in collected PFIR signal at 1492 cm⁻¹, which is on resonance with the PS domain. Figure 2d shows the lock-in collected PFIR signal at 1724 cm⁻¹, which is on resonance with the PMMA domain. Figures 2c and 2d demonstrate that the lock-in based PFIR imaging can reveal the

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chemical distribution based on their IR signatures. Figure 2e displays the collection of the lock-in based PFIR spectroscopy. The spectra were taken on the PMMA domain

(dot region) and the PS domain (flat region). The spectra show a chemical contrast between the two domains.

Next, a block copolymer film sample was measured to demonstrate the technique. The block copolymer consisted of a 7.2 mg/mL PS-*b*-PMMA (95-*b*-92, *M*_w/*M*_m = 1.10; P8537-SMMA, Polymer Source) in toluene solution spin-coated on a gold substrate. The spin-coater was set to 620 rpm for 6 seconds and 2800 rpm for 60 seconds. Figure 3a displays the topography of an area on the polymer blend. Figure 3b gives the simultaneously collected adhesion through the PeakForce Tapping QNM. Figure 3c shows the lock-in collected PFIR signal at 1492 cm⁻¹, which is in resonance with the PS domain. Figure 3d shows the lock-in collected PFIR signal at 1724 cm⁻¹, which is in resonance with the PMMA domain. Note that there was some scanner drift between the collection of 3c and 3d, which is possible for open-loop AFMs, like the Multimode 8 utilized here. Figures 3c and 3d agree with the PS:PMMA polymer blend results of Figure 2 in the sense that the lock-in based PFIR imaging can reveal the chemical distribution based on their IR signatures.



Figure 3. Lock-in PFIR imaging and spectroscopy of a PS-b-PMMA block copolymer film. (a,b) AFM topography and adhesion. (c,d) Lock-in based PFIR images at 1492 cm⁻¹ and 1724 cm⁻¹ at the infrared absorption peaks of PS and PMMA, respectively.

We also tested a representative biological sample of *E. coli*. The sample preparation was described in literature.²⁴ Figure 4 displays the measurement results. Figure 4a shows the topography of the *E. coli* cell. Figures 4b, 4c, and 4d display the lock-in collected PFIR images at 1552 cm⁻¹, 1644 cm⁻¹, and 1744 cm⁻¹. The wavenumber of 1552 cm⁻¹ is on resonance with amide II of protein, 1644 cm⁻¹ with amide I, and 1744 cm⁻¹ with lipids. Figure 4e displays the lock-in collected spectrum at five different locations on the *E. coli* bacteria marked in Figure 4a.

The measurement demonstrates the feasibility of lock-in based PFIR microscopy for other types of samples like biological ones.



Figure 4. Lock-in PFIR imaging and spectroscopy of *E. coli*. (a) AFM topography of the *E. coli* bacteria. (b,c,d) Lock-in PFIR images of *E. coli* at 1552, 1644, and 1744 cm⁻¹ under the infrared absorption peaks of amide II, amide I, and lipids, respectively. (e) PFIR spectra after spline smoothing of five locations on the *E. coli* bacteria in panel (a).

Discussion

The advantage of lock-in based PFIR microscopy stems from its simplicity in instrument setup and ease of operation. The lockin based PFIR implementation is much less complicated than for the regular PFIR one. The lock-in amplifier does both signal acquisition and signal processing of real-time collected mechanical signals without additional software/hardware programming, as required in regular PFIR microscopy. Compared to other lock-in based AFM-IR techniques, lock-in based PFIR microscopy inherits the advantages of PFT mode. The surface integrity of the sample is well preserved in PFT mode, in opposition to contact mode that leaves samples susceptible to deformation due to improper parameter settings. PFT mode is easy to operate with simple parameter settings, particularly with the Scanasyst® of peak force tapping mode. In contrast, PiFM or tapping mode AFM-IR requires setting up multiple operation parameters, such as a suitable tapping amplitude and adjustment of the repetition rate of the excitation lasers, which are critical to their successful operation. 1 2 Journal Name

3 While advantages present themselves in lock-in based PFIR 4 microscopy, there are still deficiencies when compared to 5 regular PFIR microscopy. The lock-in amplifier constantly 6 acquires and processes the cantilever deflection signals during 7 its operation, regardless of whether the tip is in contact or 8 detached from the sample surface during the PFT cycle. The 9 detached regime does not contribute to useful signal, although 10 noise from the detachment regime still contributes to the noise 11 background. However, only the contact regime contains useful 12 sample-specific photothermal responses. Regular PFIR 13 microscopy avoids this issue because the cantilever deflection 14 signals from the detachment regime are not acquired, thus 15 avoiding the contribution of noise to the signal. In lock-in based 16 PFIR microscopy, such an increase in noise contribution is 17 inevitable, imposing a trade-off between performance and 18 19 instrumental complexity. In addition, the recently developed dual-color PFIR microscopy²⁴, allows two PFIR images to be 20 collected simultaneously without relative drift. In the case of 21 lock-in amplifier based PFIR microscopy, utilization of multiple 22 23 IR sources is not straightforward, if possible, at all.

24 In our lock-in based PFIR microscopy, the laser emission is 25 generated by a pack of TTL pulses described in Figure 2b. One 26 can considered the TTL trigger pulses are created on a carrier 27 frequency at the lock-in reference frequency, with the envelope 28 determined by the PFT timing. The resulting photothermal 29 expansion of the sample is phase-synchronized with the 30 reference frequency from the lock-in amplifier. Therefore, the 31 lock-in time constant can set at an arbitrarily long value to 32 33 increase signal-to-noise ratio, albeit reducing the acquisition speed. The TTL reference frequency F is set at integer multiple 34 of the PFT frequency f, so within each pack, there are integer 35 number of trigger pulses with well-defined spacing at 1/F. This 36 37 configuration ensures that the laser pulse triggered by the rising 38 edge of the TTL pulses are equal spaced in time.

Conclusions

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58 59 60 In summary, we have developed a lock-in based PFIR microscopy that simplifies the design of the original PFIR microscopy. We demonstrated this new method on nanostructured polymers and biological cells. The ease of setup and operation of a lock-in based PFIR microscopy will reduce the adoption barrier for PFIR microscopy as a nanoscale infrared chemical identification tool.

Author Contributions

X. G. X. generated the idea of lock-in based PFIR after discussion with M. W. Both X. G. X. and A.D. built the experimental setup. A.D. collected the data. Q. X. provided assistance during data collection. X.G.X and A. D. wrote the manuscript.

Conflicts of interest

M. W. is employed by Bruker Nano Surfaces Division, a manufacturer of instrumentation for AFM-based infrared spectroscopy. M.W and X.G.X. hold patents in AFM-based infrared spectroscopy.

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